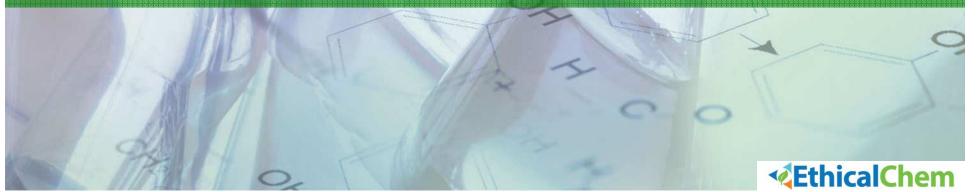
Ethical Chemical Chemical Solutions LLC

Surfactant Enhanced Product Recovery for Creosote Remediation

Dan Socci, CEO 2014





Green Chemical Solution for Remediation and Oil Industries

ETHICALCHEM BACKGROUND



EthicalChem Background

- Recently acquired the intellectual property assets of VeruTEK Technologies Inc.
- Provides plant-based, green chemical solutions for the oilfield and remediation industries

Remediation Technologies	Oilfield Technologies	
 SEPR™ (Surfactant Enhanced Product Recovery) S-ISCO[®]	 Viscosity reduction Demulsification Drilling muds removal Wellbore cleaning Oily wastewater separation 	



Field Proven Technologies



- ✓ 50+ remediation sites completed
- ✓ 20+ oil fields
- ✓ 10 patents







Green Chemical Solution for Environmental Remediation

CREOSOTE REMEDIATION WITH SEPR



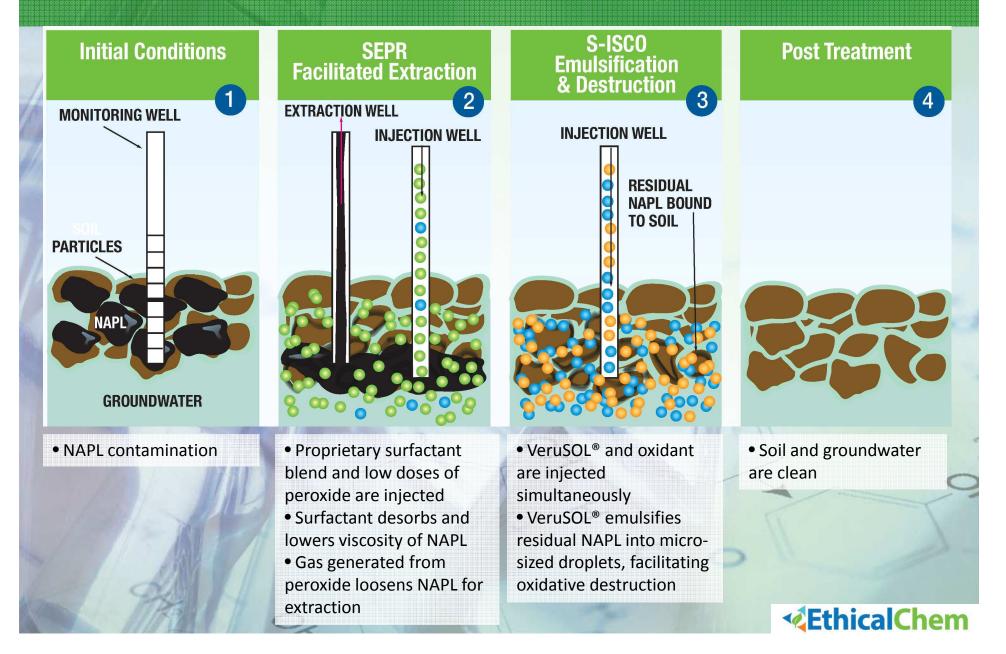
Remediation Technologies

- Surfactant-enhanced In Situ Chemical Oxidation (S-ISCO)
 - Desorbs and destroys residual contamination in place
 - Simultaneous injection of surfactant and oxidant

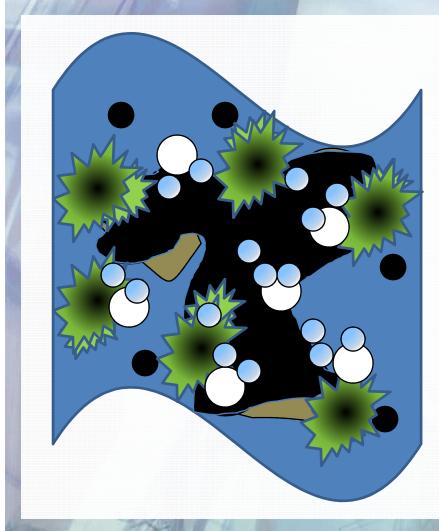
- Surfactant Enhanced Product Recovery (SEPR)
 - Desorbsion and gas generation improves recovery of Non-Aqueous Phase Liquid (NAPL) contamination
 - Implemented first to maximize S-ISCO performance



SEPR Technology



SEPR Performance

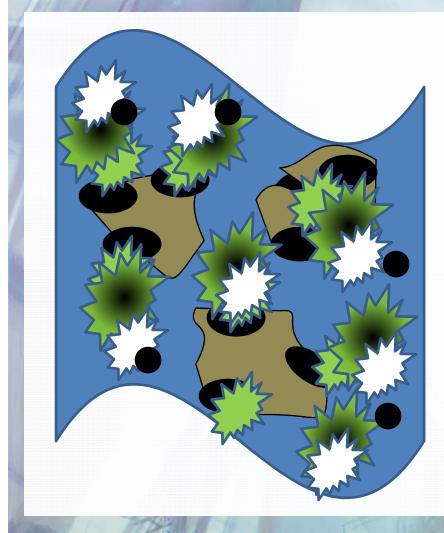


- Bulk, free phase NAPL present in subsurface
- SEPR fluid injected
- Surfactants desorb and emulsify NAPL
- Gas bubbles generated from peroxide

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- Movement to recovery wells
- Residual contamination remains

S-ISCO Performance



- Sorbed contaminants on soil and in soil pores
- Surfactant and oxidant introduced into groundwater
- Sorbed contaminants are emulsified into aqueous phase
- Removal of source contamination no rebound

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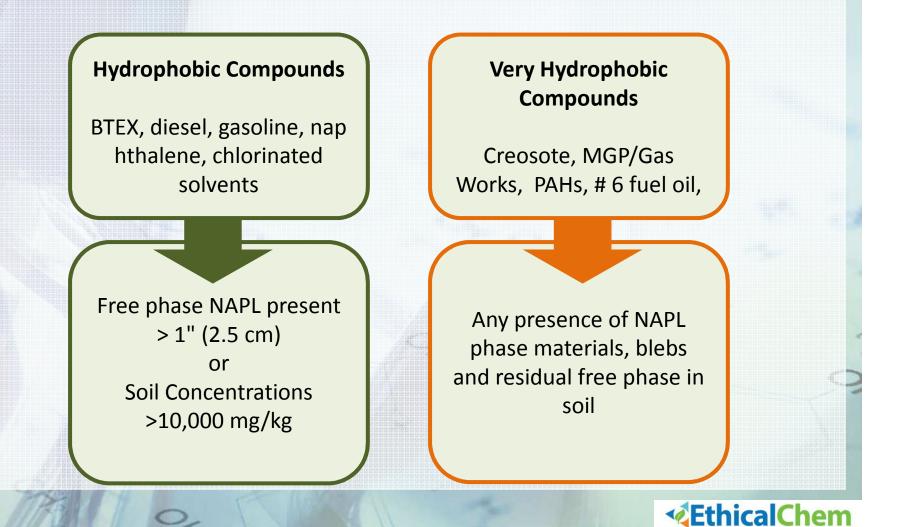
Pre and Post S-ISCO Implementation



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SEPR Technology

When to Implement SEPR





SEPR Implementation for Creosote Remediation

CASE STUDY EXAMPLES





Site Former Wood Treatment Facility, Bridgeville, DE

Contaminants of Concern Creosote DNAPL

Objectives

Demonstrate efficacy of SEPR & S-ISCO technologies for remediation of creosote DNAPL

Remedial Implementation SEPR & S-ISCO



Site Background

- Lumber Treating Facility (1963 1986)
- DNREC-Hazardous Substances Cleanup Act (HSCA) Program
- Creosote waste oil & condensate water was gravity-fed into unlined waste lagoon (1000 ft²)
- Lagoon was excavated in 1986 but the vertical extent of NAPL was greater than originally reported
- Subsequent investigations uncovered NAPL free product in monitoring wells & present in the test pits



Remedial Design

• Observations of free product and/or residual DNAPL in soil borings were used to define the area of the DNAPL plume in each 1-ft interval from 6 to 15 ft below ground surface (bgs).

• Target:

 \circ 4,180 gal of creosote DNAPL \circ 510 yd³ of soil, 6 –15 ft bgs.

• Treatment:

SEPR to remove DNAPL
S-ISCO to remove residual contamination



Implementation: Area I

- SEPR 18 days
 - Injection of 5,000 gal
 - Hydrogen Peroxide (0.5 4%)
 - Surfactant (10 30 g/L)
 - Extraction of 4,400 gal of DNAPL and fluid

S-ISCO – 6 weeks

- Injection of 27,000 L
- VeruSOL (5 10 g/L)
- Hydrogen Peroxide (4 8%)
- Sodium Persulfate (50 100 g/L)



Implementation: Area II

- SEPR 6 weeks
 - Injection of 8,900 gal
 - Hydrogen Peroxide (up to 4%)
 - Surfactant (5 10 g/L)
 - Extraction of 3,200 gal of DNAPL and fluid

S-ISCO – 2 weeks

- Injection of 3,800 gallons
- VeruSOL (5 10 g/L)
- Hydrogen Peroxide (4 8%)
- Sodium Persulfate (50 100 g/L)







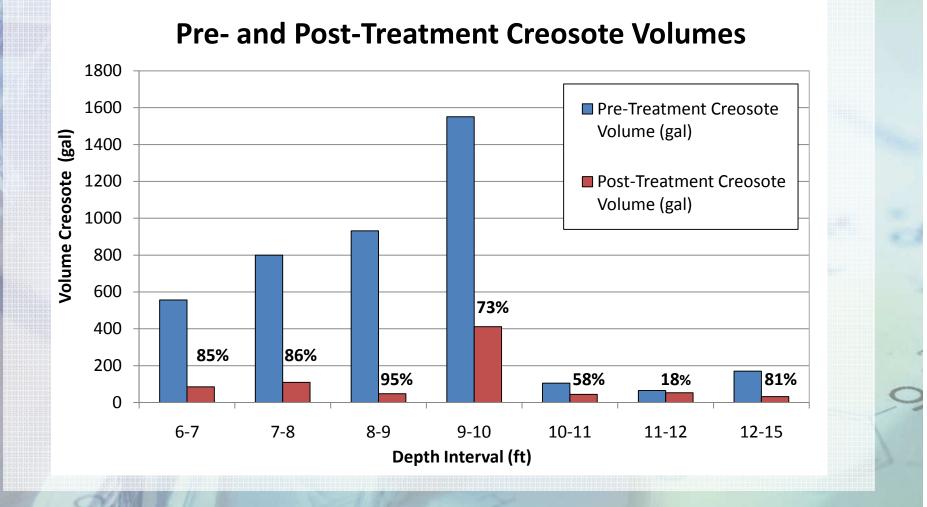






End of S-ISCO Treatment





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Result Summary

Area I:

• 87% of contaminant mass was removed from 6 to 10 ft interval, where majority of creosote was located

• Led to immediate expansion of treatment for Area II

Area II

81% of DNAPL was removed from treatment area

Cost of remediation <\$100/cubic yard



Creosote Remediation with SEPR Technology U.S. Gulf State



Site

 34 acre Former Wood Treating Facility,

Contaminants of Concern

Creosote DNAPL

Objectives

- Enhance well yield of the existing recovery system in saturated zone
- Reduce soil concentrations of TPH in vadose zone





Treatment Details:

- 3 stage treatment approach
 - Vadose zone NAPL removal
 - Well rehabilitation (in saturated zone)
 - Improved saturated zone NAPL removal

SEPR Chemistry

- Up to 8% hydrogen peroxide
- 1-5% VeruSOL Creosote formula



Total fluid recovered: 32,000 gallons Pilot Test duration: 9 weeks

Treatment Stage	Vadose Zone	Saturated Zone	
SEPR Chemistry	8,600 gallons total	24,000 gallons total	
Treatment Area	275 sq. ft	1.5 acres	
Treatment Depth	9ft – 19ft	16ft -29ft	_
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Saturated Recovery Well Performance

Well	Pre SEPR Average Yield (gpm)	Post SEPR Average Yield (gpm)	% Increase
R5	0.82	2.40	193%
R9	0.16	1.11	594%
R10	0.11	0.23	109%
R12	0.24	1.27	429%
R15	0.31	0.67	116%
R17	0.04	0.54	1250%
R18	0.15	0.45	200%





Frac Tank Containing Extracted Fluid



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Results:

- Enhanced recovery rates by up to 1200% in saturated zone
- Achieved 84% TPH mass reduction in the vadose zone
- Enhanced removal of free phase creosote NAPL from the vadose and the saturated zone







FAQs: Mobilization

Q: Will surfactant use cause undesirable contaminant mobilization?

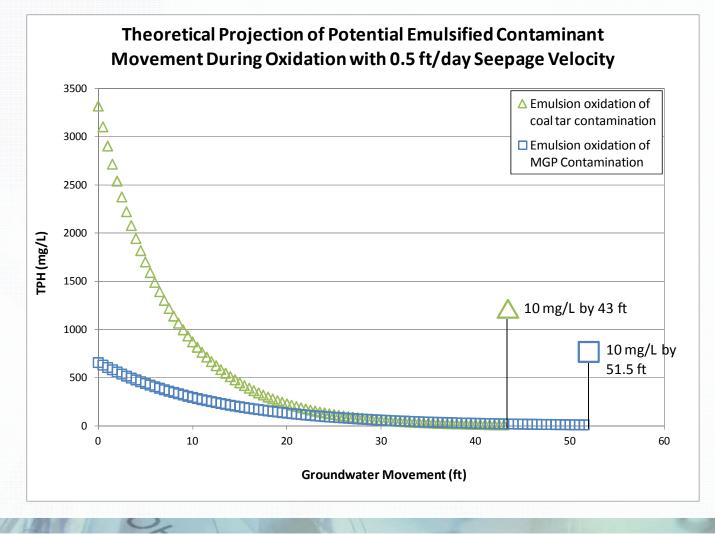
Surfactant and oxidant are injected together as a homogeneous solution

Injected chemistry travels together through subsurface

- Emulsification and oxidation take place simultaneously over time
- VeruSOL typically remains in the soil about a month due to biodegradation and oxidation
- Groundwater speeds typically do not carry emulsion offsite prior to destruction

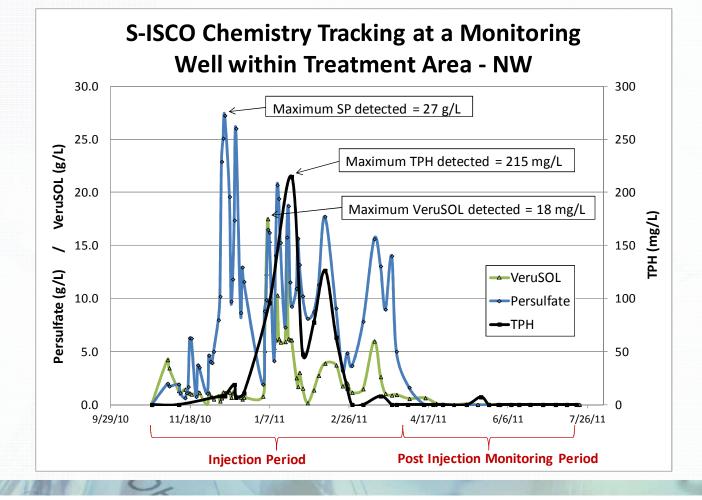
FAQs: Mobilization

Field and lab projection of two emulsions, traveling vs. destruction



FAQs: Mobilization

 S-ISCO chemistry traveling together – data from an on site monitoring well during and after injections



FAQs: Surfactant Consumption by Oxidant

Q: Will the surfactant be consumed by the oxidant

Contaminants are more susceptible to oxidation than surfactant

Contaminants will be oxidized first

